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: Applicant(s)

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LIST OF PRIOR ART CITED BY APPLICANT(S)

(Use several sheets if necessary)

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U.S. PATENT DOCUMENTS

Previously Considered

EXAM. NO.	DOCUMENT NUMBER	DATE	NAME	CLASS/SUBCLASS	FILING DATE
AA:	5440482	08/08/95	Davis	364/419.13	03/25/93
AB:	5485373	01/16/96	Davis et al.	364/419.13	03/25/93
AC:	5758314	05/26/98	McKenna	704/8	05/21/96
AD:	5787452	07/28/98	McKenna	707/536	05/21/96
AE:	5793381	08/11/98	Edberg et al.	345/467	09/13/95
AF:	5832507	11/03/98	Harper et al.	707/200	04/01/96
AG:	5873111	02/16/99	Edberg	707/536	05/10/96

FOREIGN COUNTRIES

DOC. NO.	DATE	COUNTRY	CLASS/SUBCLASS	TRANSLATION YES : NO
BA:EP0852037	01/12/99	EP	G06F 17/22	X
BB:WO 97/10556	20/03/97	PCT	G06F 17/22	X
BC:JP10260884	09/29/98	Japan	G06F 12/00	Abstract only

OTHER PRIOR ART (INCLUDE. AUTHOR, TITLE, DATE, PERTINENT PG., ETC.)

No references

:CA: "National Language Support Reference Manual" IBM National Language
: : Design Guide Volume 2, 4th Edition, August 1994.

:CB: "National Language Support Bidi Guide", IBM National Language
: : Design Guide Volume 3, 1st Edition, October 1995.

:CC: "Language Reference" IBM High Level Assembler for MVS® & VM & VSE,
: : Release 3, 3rd Edition, September 1998.

:CD: "Programmer's Guide", IBM High Level Assembler for MVS® & VM
: : & VSE, Release 3, 3rd Edition, September 1998.

:CE: "National Language Support" IBM AS/400e series, Version 4,
: : 2nd Edition, February 1998.

:CF: "The Unicode Standard Version 3.0", The Unicode Consortium.
: : 2nd Printing, April 2000.

:CG: "Designing Internationalized Products" IBM National Language
: : Design Guide, 4th Edition, October 1996.

EXAMINER

DATE CONSIDERED

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant (s).